

1 keV to 50 keV
UNIFORM HIGH POWER FLOOD ELECTRON BEAMS

FOR USE IN:

- ▶ General Vacuum Physics
- ▶ Spacecraft Materials Testing
- ▶ UHV Charging
- ▶ Surface Physics

FEATURES / OPTIONS:

- ▶ Uniform Flood Beam
- ▶ Rastering / Beam Washing for Wide Angle Uniform Spot
- ▶ Electrostatic Divergence Control
- ▶ Magnetostatic Deflection
- ▶ Internal Alignment while Operating
- ▶ User-replaceable Firing Units
- ▶ 2.75 inch CFF Mounting
- ▶ UHV Technology / Bakeable
- ▶ Computer / Remote Control
- ▶ LabVIEW™ Computer / Programming



EGF-6115 Electron Gun mounted on 2.75 inch CF Flange (shown without Deflection)

The Kimball Physics EGF-6115 Electron Gun with its matching EGPS-6115 Power Supply is a complete subsystem ready to attach to the user's vacuum system and turn on. It can deliver electrons over a broad range of energies, currents and power. The EGH-6115 is a high-power, focusable flood gun for use in spacecraft materials testing and other surface physics and general vacuum physics applications.

The gun can generate a high energy, adjustable divergence, flood electron beam. Both beam energy and beam current are independently adjustable over wide ranges; energies from 1 keV to 50 keV and currents from picoamps to five milliamps can be achieved. The electron beam can be pulsed by an input signal to the control grid.

The adjustable optics of the gun can adapt to different divergences and different working distances. Rastering / beam washing is used to provide a large uniform spot. Electrostatic focusing provides control of the spot size, which is typically in the tens of centimeters. The flood beam is also partially dependent on the grid, anode and working distance.

The firing unit cartridge (including the cathode, cathode-mount, and Wehnelt aperture) is user-replaceable without removing the entire gun from the vacuum chamber; used firing units may be returned to the factory for rebuild.

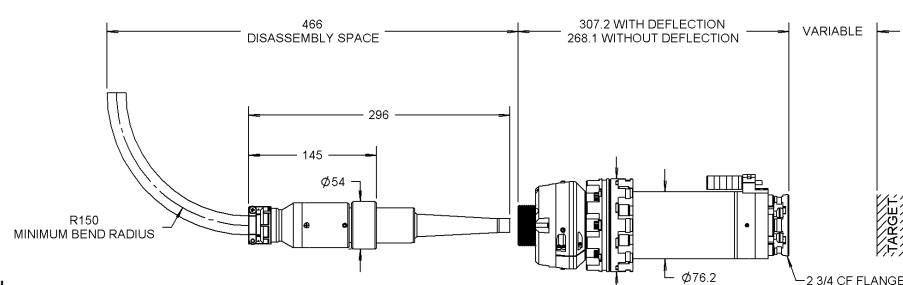
Several cathode types and sizes are available: tantalum disc cathodes,

yttria-coated (Y_2O_3) iridium cathodes, or Barium Oxide coated (BaO) cathodes. These cathodes (with the exception of BaO) are not damaged by repeated exposure to atmospheric gases or water vapor when cold.

UHV technology is used throughout. The gun can be run in vacuums from 10^{-11} torr to 10^{-6} torr for the metal cathodes, or to 10^{-7} torr for BaO cathodes. The yttria-coated iridium cathode can survive a total vacuum dump. The electron gun is bakeable to 350°C with cables and electronics box removed. The gun is usually mounted on a 2.75 inch CF flange, and it has zero insertion distance into the vacuum chamber.

The EGPS-6115 Power Supply System contains all necessary power supplies to run the EGF-6115 Electron Gun. The power supply system includes a separate HV supply, connected to, and controlled by the EGPS-6115.

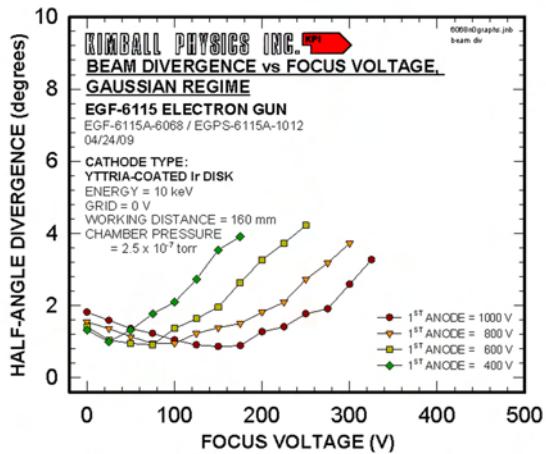
An optional LabVIEW™ computer program designed for the EGF-6115 is available for remote computer control and metering. Software is available in two types: Standard configuration is via serial connections, or an option using National Instrument DAQ boards and SCSI connectors on the EGPS-6115 is available. The program provides a virtual panel of controls and real-time metering on the user's computer screen.



EGF-6115 ELECTRON GUN
(Dimensions in mm)

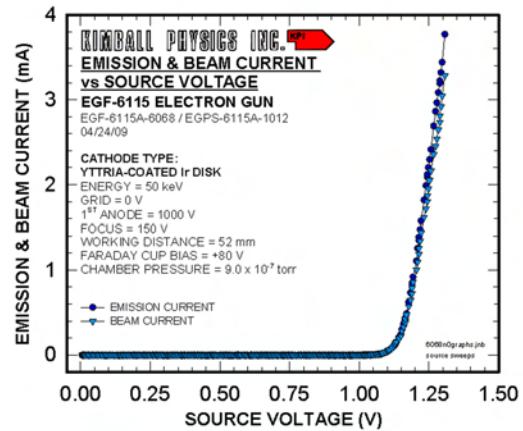
EGF-6115 ELECTRON GUN SPECIFICATIONS		EGPS-6115 ELECTRON GUN POWER SUPPLY SPECIFICATIONS	
BEAM ENERGY	1 keV to 50 keV (Independently adjustable)	OUTPUT	All necessary voltages to drive the EGF-6115 Electron Gun.
BEAM CURRENT	1 nA to 5 mA (Independently adjustable) Low Current option: 100pA to 100nA	ENERGY STABILITY	<0.01% per hour with 0.05% rms ripple at full output
ENERGY SPREAD	Approx. 0.4 eV cathode thermal spread, calculated	BEAM STABILITY	±0.1% per hour with Emission Current Control or ±10% per hour after warm up without ECC
BEAM DIVERGENCE	Variable. Adjustable optics to adapt to different divergences and different working distances	CONTROLS	FlexPanel controls: Energy, Focus, Anode, Grid, Source Voltage, Emission Current Control, optional Raster X and Y Size and Frequency
SPOT SIZE	15 mm to 50 mm at 100 mm working distance	METERING	FlexPanel digital meters: Energy, Focus Anode, Emission, Grid, Source Volts, Source Current
WORKING DISTANCE	100 mm to 1000 mm	COMPUTER/REMOTE CONTROL & METER	All power supplies: 0 to +10 volts or -10 to +10 volts All meters: 0 to +2 volts
BEAM DEFLECTION	Magnetostatic: ± 20° at 50 keV (Optional)	SOFTWARE	Standard configuration designed for RS-232 connectors. Optional: National Instruments LabVIEW™ file, designed to run with computer DAQ boards NI 6713 / 6036. SCSI optional
RASTERING/BEAM WASHING	Magnetic: Improves beam uniformity (optional)	INPUT	115 VAC or 230 VAC, 50 to 60 Hz, 100 W
PULSE CAPABILITY	Optional Dual Grid Power Supply: pulse width 2 µs to DC, rep rates to 1 kHz, rise/ fall 500 ns, rep rates to 5 kHz using appropriate pulse generator (not supplied)	DIMENSIONS	Approx: 17 in. x 7 in. x 22 in. (432 mm x 180 mm x 560 mm); with rack mount kits, overall width is 19.5 in. (495 mm)
BEAM UNIFORMITY	Center to outer edge ±10%, with rastering and appropriate gun potentials		
FIRING UNIT	Customer-replaceable Firing Unit Cartridge includes precision-aligned cathode, and Wehnelt (G-1) assembly Firing unit also includes first anode		
CATHODE TYPES	Tantalum (Ta) disc, Yttrium oxide (Y_2O_3) or Barium Oxide (BaO). Cathodes (with exception of BaO) not harmed by repeated exposure to atmosphere while cold		
MOUNTING	Standard: 2.75 inch CF flange		
INSERTION LENGTH	Zero mm		
GUN DIMENSIONS	Gun length: 432 mm (393 W/O deflection) sealing surface to end of cable connector, Gun dia: 76 mm		
FEEDTHROUGHS	Multi-pin brazed ceramic with threaded stainless shell		
CABLES	Multiconductor high voltage fully ground-shielded, with mating aluminum connector to connect gun to power supply.		
MAXIMUM BAKEOUT	350°C with cables removed		

A typical lab set-up of a complete Kimball Physics high energy system with an flood-style electron gun, power supplies and optional computer control system (details vary with gun model)



OPTIONAL RASTERING / BEAM WASHING SPECIFICATIONS

RASTER GENERATOR	Frequency in X and Y directions can be independently set. X freq. is up to 500 Hz, Y freq. 100Hz. (Frequencies above 100 Hz reduce total raster angle). All parameters controllable via RS-232, RS-422, RS-485, analog input, or computer control with LabVIEW™ software option.
DIMENSIONS	Included in dimensions for standard EGPS (above)



Typical performance;
data for guidance only.

